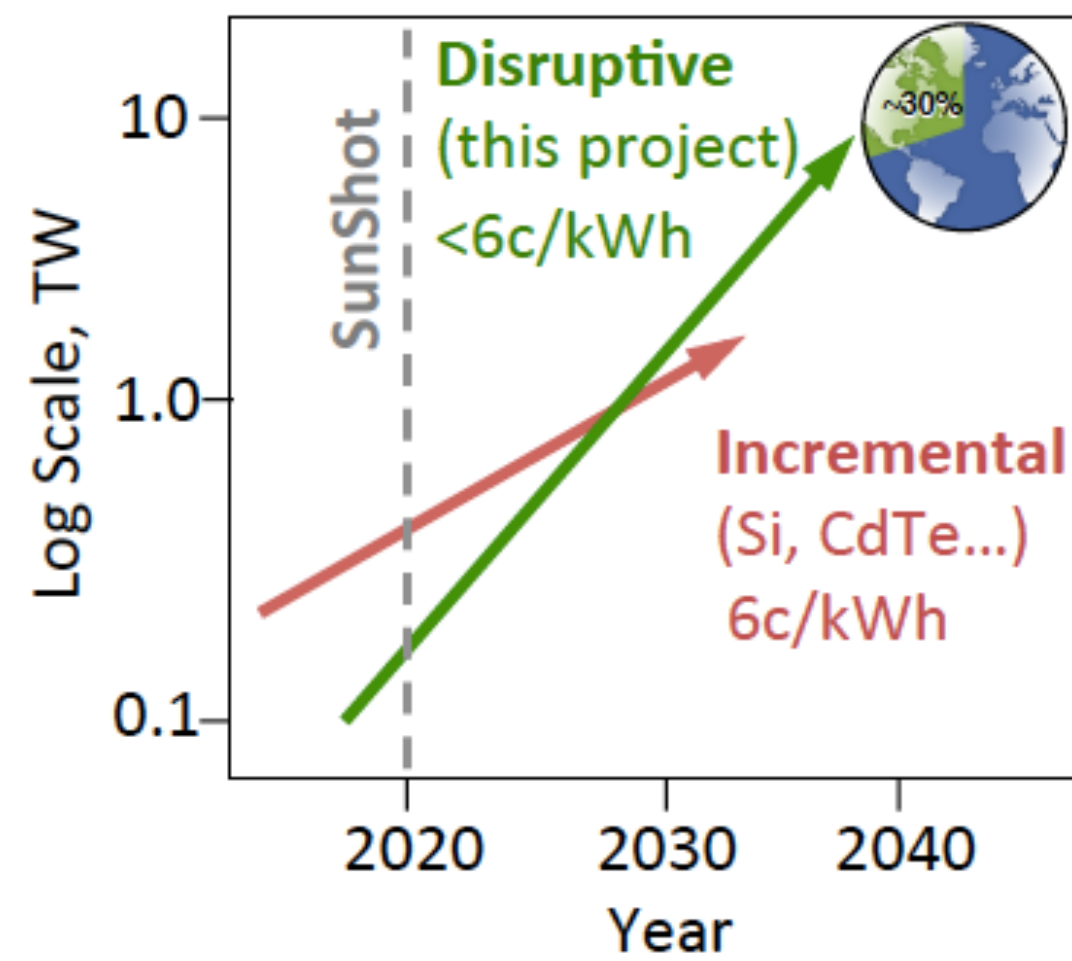


# Rapid Development of Nitride- and Oxide- Based Disruptive PV Technologies

E. Arca, A. N. Fioretti, S. Lany, A. C. Tamboli, G. Teeter, C. Melamed, H. Peng, A. Bikowski, J. Pan, K. Wood, E. S. Toberer and A. Zakutayev - National Renewable Energy Laboratory

## “Rapid Development” project

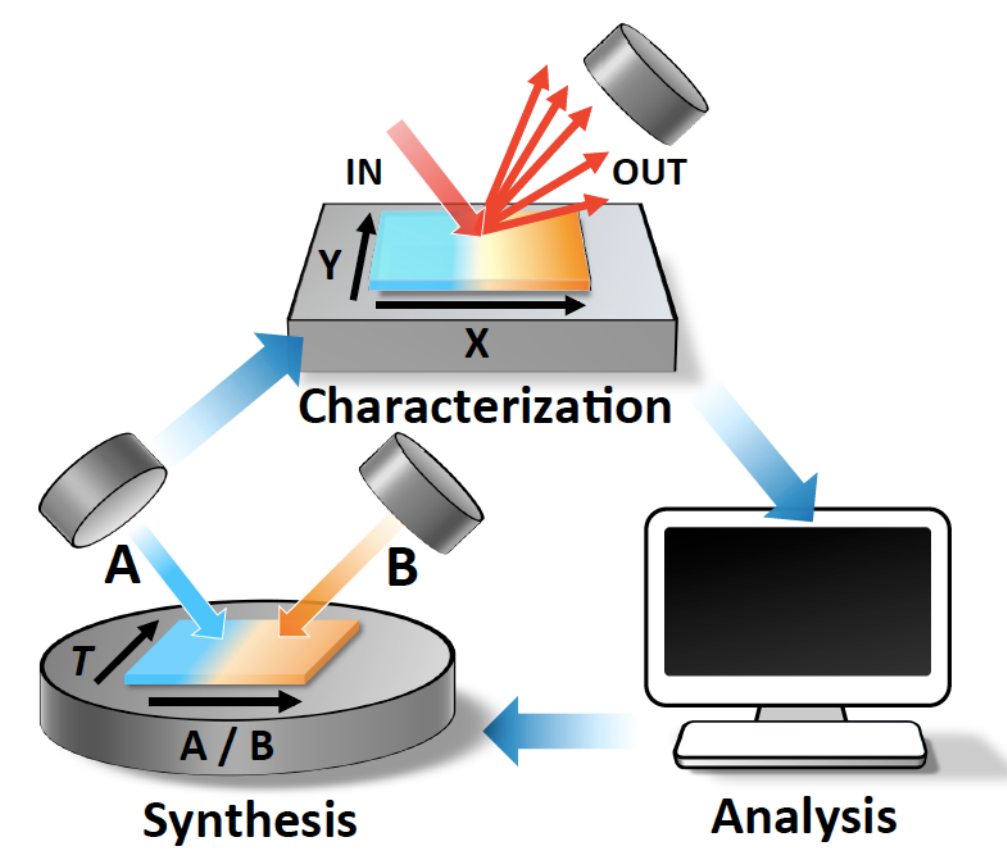
### Project summary



S. Lany, T. Gershon, A. Zakutayev, *Journ. Opt.*, 18, 073004 (2016)  
A. Zakutayev, *Curr. Opinion. Green. Sust. Chem.* 4, 8, (2017)

Remarkable progress has been achieved in incremental cost reduction of Si and CdTe solar cells towards 1TW level of deployment. However disruptive PV technologies that can be scaled more easily are needed to reach ~10TW level. This project aims to establish disruptive PV technology based on defect-tolerant oxide- and nitride absorbers.

### Project Approach



### First-principles computations

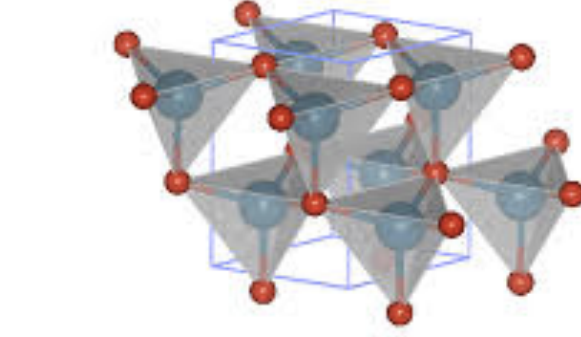
- Leveraging “Center for Next Generation of Materials by Design” EFRC
- Accurate calculations results in database: materials.nrel.gov

### Combinatorial synthesis:

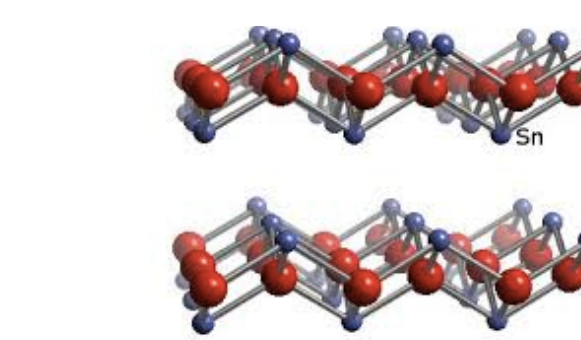
- Composition/Temperature gradients
  - Not only materials, also devices
- ### Spatially-resolved characterization:
- Composition, structure/phase
  - Optoelectronic properties
- ### Semi-automated data analysis:
- Close comparison with theory
  - Database development in progress

### Project Materials

Nitrides:  $\text{ZnSnN}_2$



Oxides:  $(\text{Sn},\text{M})\text{O}$



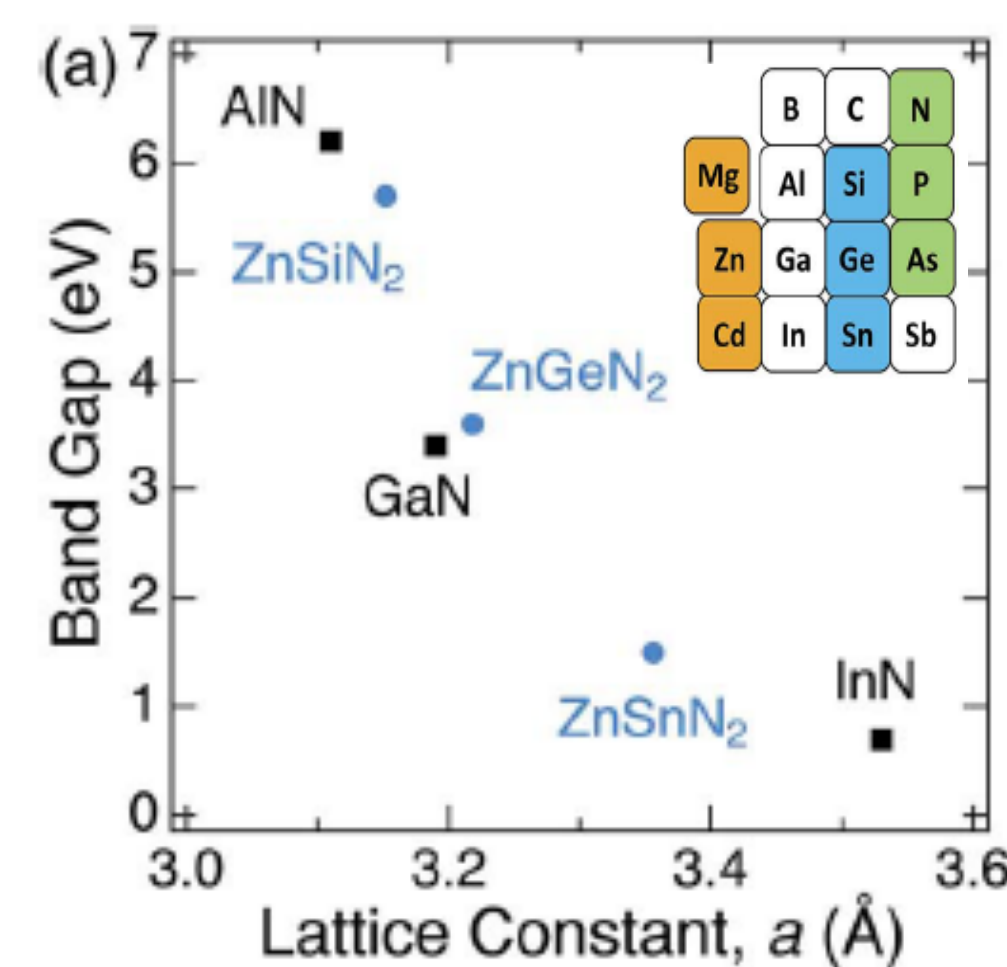
A. Zakutayev, S. Lany et al *J. Phys. Chem. Lett.* 5, 1117 (2014)  
A. Zakutayev *J. Mater. Chem. A* 4, 6742 (2016)

Oxide and Nitride absorbers:

- Suitable for large-scale manufacturing by commercial in-line sputtering:
- $\text{ZnSnN}_2$  – ionic materials tend to have defects than covalent materials
- $(\text{Sn},\text{M})\text{O}$  – anti-bonding VBM may lead to additional defect tolerance

## Nitride absorber materials

### II-IV- $\text{N}_2$ absorber motivation

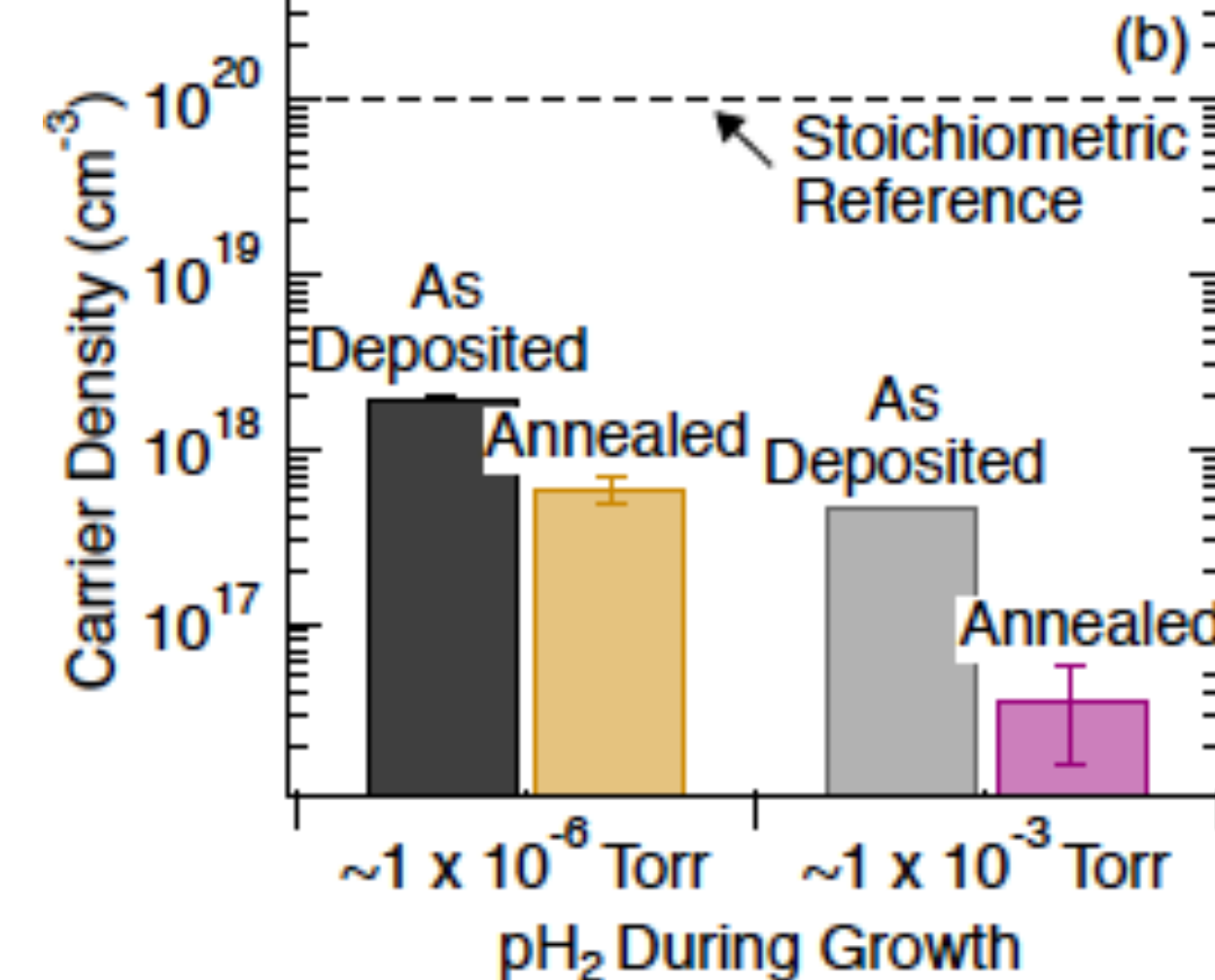


A. D. Martinez, A. N. Fioretti, E. S. Toberer, A. C. Tamboli  
B. J. Mater. Chem. A, 2017,5, 11418

II-IV- $\text{N}_2$  absorber promise:

- Replace costly III-V absorber semiconductors and overcome the miscibility gap of III-V alloys
- Possibility of tunable band gap and constant lattice constant by cation disorder

### $\text{ZnSnN}_2$ doping control

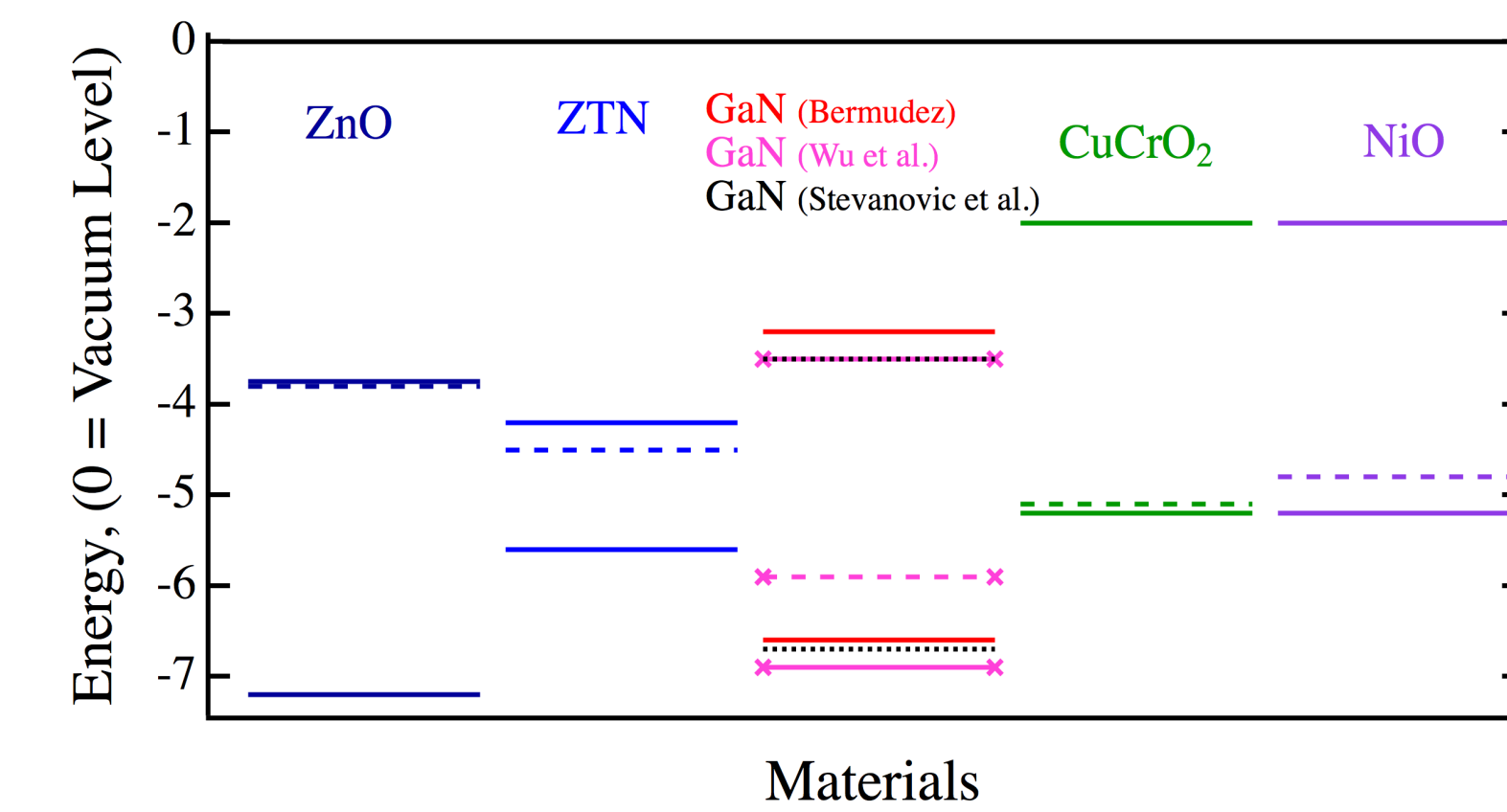


A. A. N. Fioretti, E. S. Toberer, A. C. Tamboli, A. Zakutayev et al  
*J. Mater. Chem. C*, 3, 11017 (2015); *Adv. Electron. Mat.* 3, 1600544, (2017)

Doping in  $\text{ZnSnN}_2$  can be controlled:

- By controlling Zn concentration at low temperature ( $10^{18} \text{ cm}^{-3}$ )
- By growing Zn-rich samples in  $\text{H}_2$  and then annealing ( $10^{17} \text{ cm}^{-3}$ )

### $\text{ZnSnN}_2$ band edge positions



E. Arca, A. N. Fioretti, S. Lany, A. C. Tamboli, G. Teeter, C. Melamed, J. Pan, K. Wood, E. S. Toberer and A. Zakutayev, , *IEEE PVSC* 2017

- Position of VB and CB determined by a combination of XPS, UPS, Kelvin Probe
- GaN has a band alignment unfavorable for minority carrier (holes) extraction
- $\text{CuCrO}_2/\text{NiO}$  are more favorably aligned – improvement possible by tuning the metal/oxygen ratio or Cu/Cr ratio

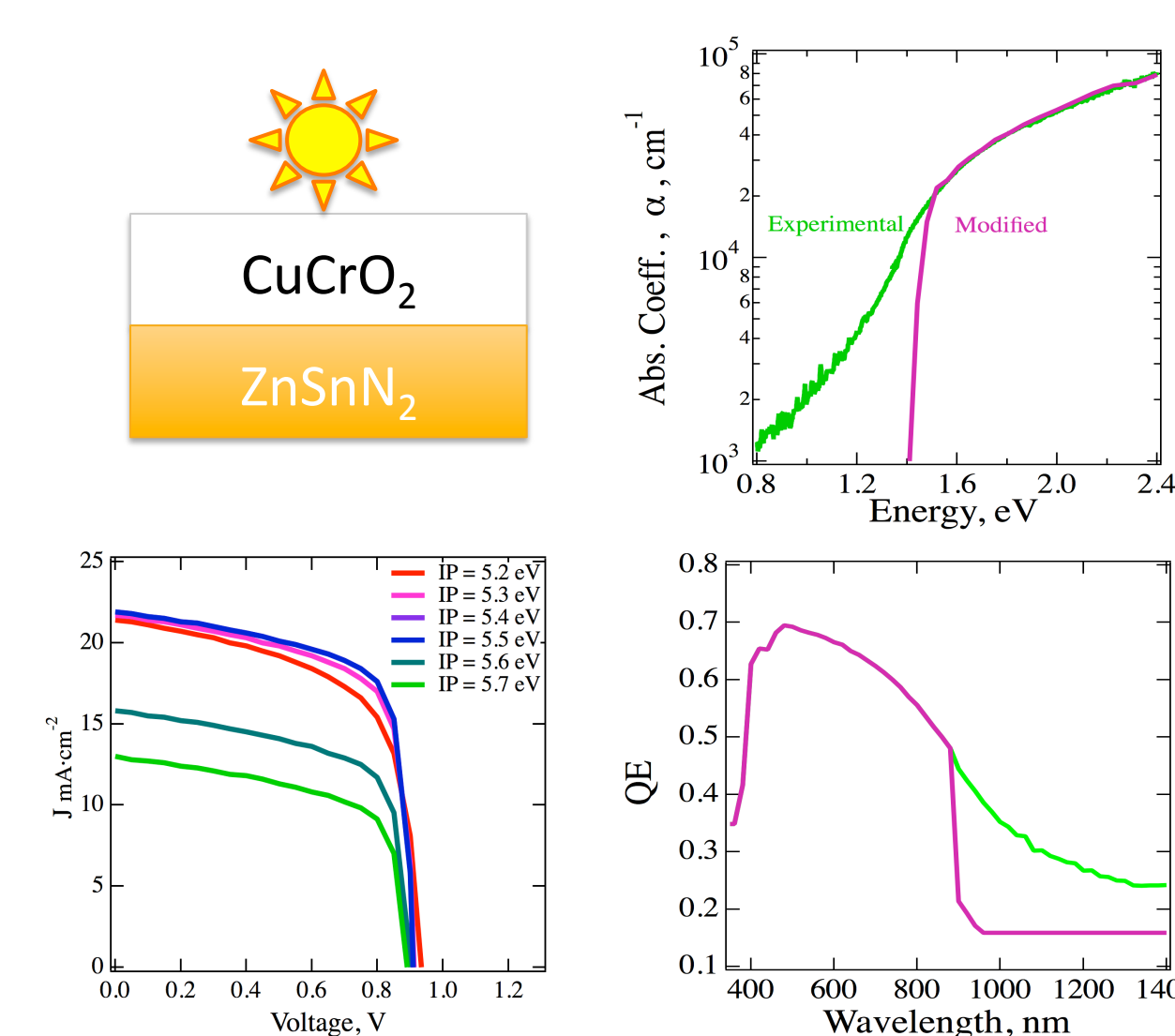
## Towards $\text{ZnSnN}_2$ PV devices

### Device simulations parameters

Input parameters (no defect model)		
$\epsilon_0$	15	7.5
EA eV	4.2	2
$E_g$ eV	1.4	3.2
$N_c \text{ cm}^{-3}$	$1.2 \times 10^{18}$	$2.8 \times 10^{20}$
$N_v \text{ cm}^{-3}$	$7.8 \times 10^{19}$	$8 \times 10^{20}$
$\mu_n \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	0.5	0.1
$\mu_p \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	0.05	0.1
$N_d \text{ cm}^{-3}$	$1.005 \times 10^{19}$	0
$N_a \text{ cm}^{-3}$	$1.001 \times 10^{19}$	$5 \times 10^{21}$
d nm	1000	50
Abs. Coef.	Modified (no tails)	Experimental
Cell's Output parameters		
$V_{oc}$ , V	1.08	
$J_{sc}$ , $\text{mA cm}^{-2}$	26.1	
FF %	80.9	
$\eta$ , %	22.9	

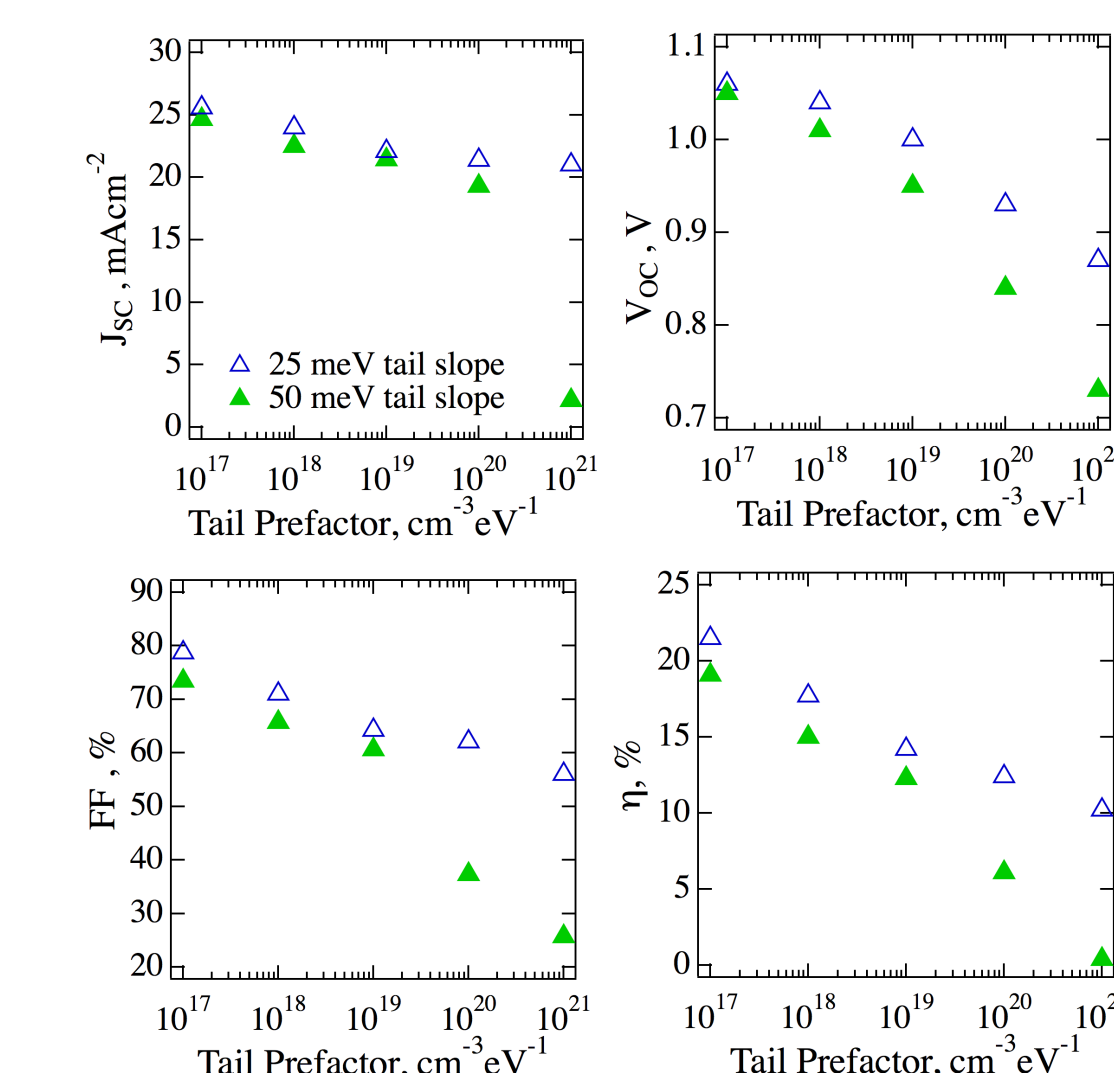
- Device simulations in absence of defects show that ZTN has potential for highly performing single junctions devices
- Defects models was built to account for:
  - Effect of tail state
  - Effect of recombination
  - Role of minority carrier mobility

### Device simulations results



- Experimental absorption coefficient shows Urbach Tail
- A modified absorption is needed to avoid artifacts in the simulation results
- JV curves as a function of IP of  $\text{Mg}:\text{CuCrO}_2$ : 0.3eV increase of its IP will improve extraction of minority carrier

### Device simulations analysis

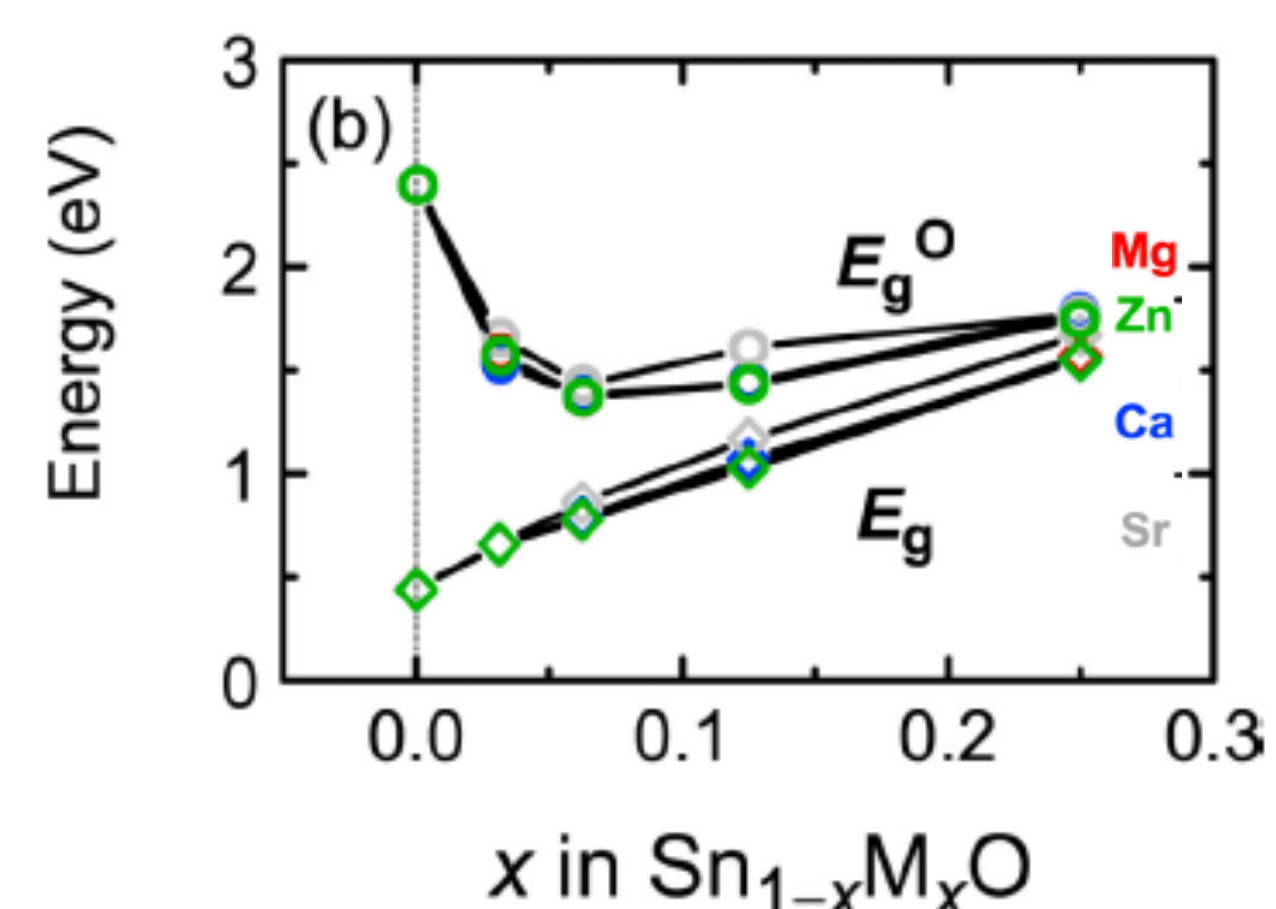


- Band tails could severely hinder device performances especially for low mobility minority carriers
- Recombination centers have a severe effect only at concentration comparable to the net carrier densities.

“Band edge positions of  $\text{ZnSnN}_2$  and their impact on the simulated performance of the solar cells”, E. Arca, A. N. Fioretti, S. Lany, A. C. Tamboli, G. Teeter, C. Melamed, J. Pan, K. Wood, E. S. Toberer and A. Zakutayev, *IEEE PVSC* 2017

## Oxide absorber materials

### $(\text{Sn},\text{M})\text{O}$ alloy motivation

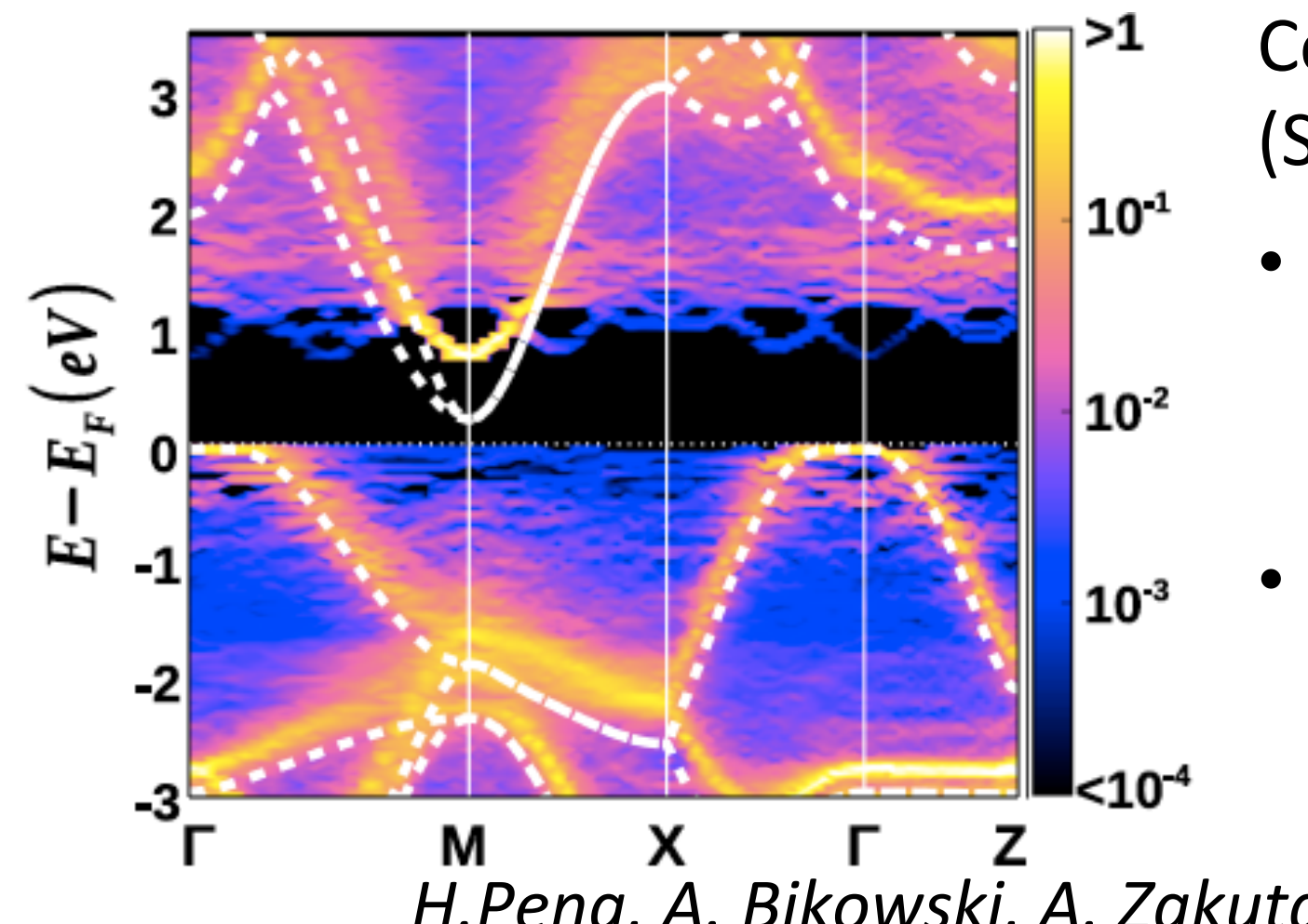


H. Peng, A. Bikowski, A. Zakutayev, and S. Lany  
*APL Mater.* 4, 106103 (2016)

$\text{SnO}$  is an interesting oxide:

- $\text{SnO}$  has very low hole mass,  $0.6 m_0$  along (001)
- $\text{SnO}$  has indirect band gap (0.7eV vs 2.7 eV)
- Alloying with Mg, Zn, Ca, Sr improves the band gap

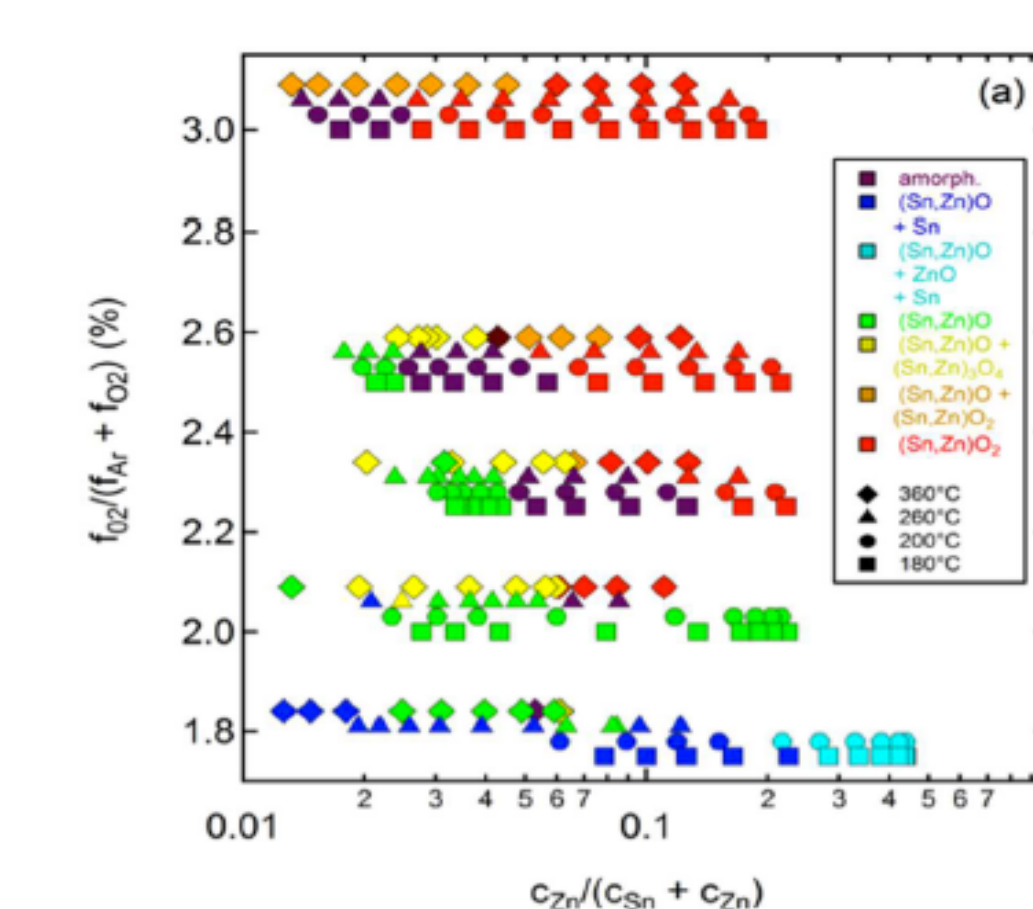
### $(\text{Sn},\text{Zn})\text{O}$ alloy theory



Compared to  $\text{SnO}$ , the  $(\text{Sn},\text{Zn})\text{O}$  alloys have:

- Wider electronic band gap (0.7 eV for  $\text{SnO}$ , 1.0 for 12% alloys)
- Lower optical band gap (2.5 eV for  $\text{SnO}$ , 1.5 eV for 12% alloys)

### $(\text{Sn},\text{Zn})\text{O}$ alloy experiments



Combinatorial synthesis of  $(\text{Sn},\text{Zn})\text{O}$  indicates that:

- Increasing Zn concentration requires decreasing oxygen flow
- Metastable  $\text{SnO}$  alloys with up to 10-20% of Zn were synthesized